

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:

Donghul Lu)	Examiner: Gambetta, Kelly M.
)	
Application No.: 10/811,591)	Art Group: 1792
)	
Filed: March 29, 2004)	
)	
For: Enhanced Dielectric Layers Using Sequential Deposition)	
)	
)	

RESPONSE AFTER FINAL

Mail Stop AF
Commissioner for Patents
P.O Box 1450
Alexandria, VA 22313-1450

Sir:

In Response to the Final Office Action mailed August 27, 2009, Applicants respectfully request the Examiner to enter the following amendment and to consider the following remark.

CERTIFICATE OF EFS Web

I hereby certify that this correspondence is being submitted electronically via EFS Web on the date shown below to the United States Patent and Trademark Office.

Date of Deposit: September 11, 2009
Name of Person Mailing Correspondence: Debbie Casias
/Debbie Casias/ _____ /September 11, 2009/ _____
Signature _____ Date _____